

CORRECTION

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Cite this: *Nanoscale Adv.*, 2020, 2, 5478

Correction: Facile, wafer-scale compatible growth of ZnO nanowires *via* chemical bath deposition: assessment of zinc ion contribution and other limiting factors

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DOI: 10.1039/d0na90053b

rsc.li/nanoscale-advances

Correction for 'Facile, wafer-scale compatible growth of ZnO nanowires *via* chemical bath deposition: assessment of zinc ion contribution and other limiting factors' by Yu-Chen Huang *et al.*, *Nanoscale Adv.*, 2020, DOI: 10.1039/d0na00434k.

The authors regret the omission of a funding acknowledgement in the original article. This acknowledgement is given below.

This research was supported by the ANR research grant (no. ANR-17-CE39-0014).

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

